## The RF MOSFET Line **RF Power Field-Effect Transistors** N-Channel Enhancement-Mode

Designed for broadband commercial and military applications using push pull circuits at frequencies to 500 MHz. The high power, high gain and broadband performance of these devices makes possible solid state transmitters for FM broadcast or TV channel frequency bands.

- Electrical Performance MRF176GU @ 50 V, 400 MHz ("U" Suffix) Output Power — 150 Watts Power Gain — 14 dB Typ Efficiency — 50% Typ MRF176GV @ 50 V, 225 MHz ("V" Suffix) Output Power — 200 Watts Power Gain — 17 dB Typ Efficiency — 55% Typ
- 100% Ruggedness Tested At Rated Output Power
- Low Thermal Resistance
- Low C<sub>rss</sub> 7.0 pF Typ @ V<sub>DS</sub> = 50 V



# MRF176GU MRF176GV

200/150 W, 50 V, 500 MHz N-CHANNEL MOS BROADBAND RF POWER FETS



#### CASE 375-04, STYLE 2

#### MAXIMUM RATINGS

Rating	Symbol	Value	Unit	
Drain–Source Voltage	V <sub>DSS</sub>	125	Vdc	
Gate-Source Voltage	V <sub>GS</sub>	±40	Vdc	
Drain Current — Continuous	۱ <sub>D</sub>	16	Adc	
Total Device Dissipation @ T <sub>C</sub> = 25°C Derate above 25°C	PD	400 2.27	Watts W/°C	
Storage Temperature Range	T <sub>stg</sub>	-65 to +150	°C	
Operating Junction Temperature	ТJ	200	°C	

#### THERMAL CHARACTERISTICS

Characteristic	Symbol	Мах	Unit
Thermal Resistance, Junction to Case	R <sub>θ</sub> JC	0.44	°C/W

Handling and Packaging — MOS devices are susceptible to damage from electrostatic charge. Reasonable precautions in handling and packaging MOS devices should be observed.

#### ELECTRICAL CHARACTERISTICS (T<sub>C</sub> = 25°C unless otherwise noted)

Characteristic	Symbol	Min	Тур	Max	Unit
OFF CHARACTERISTICS (1)					
Drain–Source Breakdown Voltage $(V_{GS} = 0, I_D = 100 \text{ mA})$	V(BR)DSS	125	—	—	Vdc
Zero Gate Voltage Drain Current ( $V_{DS} = 50 V, V_{GS} = 0$ )	IDSS	_	_	2.5	mAdc
Gate–Body Leakage Current (V <sub>GS</sub> = 20 V, V <sub>DS</sub> = 0)	IGSS	_		1.0	μAdc

NOTE:

1. Each side of device measured separately.





### **ELECTRICAL CHARACTERISTICS** — continued ( $T_C = 25^{\circ}C$ unless otherwise noted)

Characteristic	Symbol	Min	Тур	Max	Unit
ON CHARACTERISTICS (1)					
Gate Threshold Voltage (V <sub>DS</sub> = 10 V, $I_D$ = 100 mA)	VGS(th)	1.0	3.0	6.0	Vdc
Drain–Source On–Voltage ( $V_{GS}$ = 10 V, $I_D$ = 5.0 A)	V <sub>DS(on)</sub>	1.0	3.0	5.0	Vdc
Forward Transconductance ( $V_{DS}$ = 10 V, I <sub>D</sub> = 2.5 A)	9fs	2.0	3.0	—	mhos
DYNAMIC CHARACTERISTICS (1)					
Input Capacitance ( $V_{DS}$ = 50 V, $V_{GS}$ = 0, f = 1.0 MHz)	C <sub>iss</sub>	—	180	—	pF
Output Capacitance ( $V_{DS}$ = 50 V, $V_{GS}$ = 0, f = 1.0 MHz)	C <sub>OSS</sub>	—	100	_	pF
Reverse Transfer Capacitance ( $V_{DS} = 50 \text{ V}, V_{GS} = 0, f = 1.0 \text{ MHz}$ )	C <sub>rss</sub>	—	6.0	—	pF
FUNCTIONAL CHARACTERISTICS — MRF176GV (2) (Figure	1)				
Common Source Power Gain $(V_{DD} = 50 \text{ Vdc}, P_{out} = 200 \text{ W}, f = 225 \text{ MHz}, I_{DQ} = 2.0 \text{ x} 100 \text{ mA})$	G <sub>ps</sub>	15	17	-	dB
Drain Efficiency (V <sub>DD</sub> = 50 Vdc, P <sub>out</sub> = 200 W, f = 225 MHz, I <sub>DQ</sub> = 2.0 x 100 mA)	η	50	55	-	%
Electrical Ruggedness ( $V_{DD}$ = 50 Vdc, $P_{Out}$ = 200 W, f = 225 MHz, $I_{DQ}$ = 2.0 x 100 mA, VSWR 10:1 at all Phase Angles)	Ψ	No Degradation in Output Power			

NOTES:

1. Each side of device measured separately.

2. Measured in push-pull configuration.



 $\begin{array}{l} {\rm C1-Arco}\; 404,\, 8.0-60\; {\rm pF} \\ {\rm C2,\, C3,\, C6,\, C8-1000\; pF\; Chip} \\ {\rm C4,\, C9-0.1\; \mu F\; Chip} \\ {\rm C5-180\; pF\; Chip} \\ {\rm C7-Arco}\; 403,\, 3.0-35\; {\rm pF} \\ {\rm C10-0.47\; \mu F\; Chip,\; Kemet\; 1215\; or\; Equivalent} \\ {\rm L1-10\; Turns\; AWG\; \#16\; Enameled\; Wire,} \\ {\rm Close\; Wound,\; 1/4''\; I.D.} \end{array}$ 

Board material — .062" fiberglass (G10), Two sided, 1 oz. copper,  $\epsilon_{\Gamma}\cong 5$ 

Unless otherwise noted, all chip capacitors are ATC Type 100 or Equivalent

- L2 Ferrite Beads of Suitable Material for 1.5–2.0 μH, Total Inductance
- R1 100 Ohms, 1/2 W
- R2 1.0 kOhms, 1/2 W
- T1 4:1 Impedance Ratio RF Transformer. Can Be Made of 25 Ohm Semirigid Co–Ax, 47–62 Mils O.D.
- T2 1:4 Impedance Ratio RF Transformer. Can Be Made of 25 Ohm Semirigid Co–Ax, 62–90 Mils O.D.
- NOTE: For stability, the input transformer T1 should be loaded with ferrite toroids or beads to increase the common mode inductance. For operation below 100 MHz. The same is required for the output transformer.

Figure 1. 225 MHz Test Circuit

#### **ELECTRICAL CHARACTERISTICS** ( $T_C = 25^{\circ}C$ unless otherwise noted)

Characteristic	Symbol	Min	Тур	Max	Unit	
FUNCTIONAL CHARACTERISTICS — MRF176GU (1) (Figure 2)						
Common Source Power Gain ( $V_{DD}$ = 50 Vdc, $P_{out}$ = 150 W, f = 400 MHz, $I_{DQ}$ = 2.0 x 100 mA)	G <sub>ps</sub>	12	14	-	dB	
Drain Efficiency (V <sub>DD</sub> = 50 Vdc, P <sub>out</sub> = 150 W, f = 400 MHz, I <sub>DQ</sub> = 2.0 x 100 mA)	η	45	50	-	%	
Electrical Ruggedness (V <sub>DD</sub> = 50 Vdc, P <sub>OUt</sub> = 150 W, f = 400 MHz, I <sub>DQ</sub> = 2.0 x 100 mA, VSWR 10:1 at all Phase Angles)	Ψ	No Degradation in Output Power				

NOTE:

1. Measured in push-pull configuration.



Ckt Board Material — .060″ teflon–fiberglass, copper clad both sides, 2 oz. copper,  $\epsilon_{F}$  = 2.55

Figure 2. 400 MHz Test Circuit

## **TYPICAL CHARACTERISTICS**





\* Data shown applies to each half of MRF176GU/GV





Figure 5. Series Equivalent Input/Output Impedance

## **TYPICAL CHARACTERISTICS**





300

200

100

0

0

Pout, POWER OUTPUT (WATTS)



320 I<sub>DQ</sub> = 2 x 100 mA 280 240 200 160 120 80 80 V<sub>DD</sub> = 50 V f = 225 MHz Pin = 6 W 200 40 V 4 W 2 W I<sub>DQ</sub> = 2 x 100 mA f = 225 MHz 40 0 6 12 32 34 36 38 40 42 44 46 48 50 30 Pin, POWER INPUT (WATTS) VDS, SUPPLY VOLTAGE (VOLTS)

## MRF176GV

Figure 8. Power Input versus Power Output

Figure 9. Output Power versus Supply Voltage

## TYPICAL CHARACTERISTICS MRF176GU



Figure 10. Output Power versus Input Power

Figure 11. Output Power versus Input Power



Figure 12. Output Power versus Supply Voltage

#### **MOSFET CAPACITANCES**

The physical structure of a MOSFET results in capacitors between the terminals. The metal oxide gate structure determines the capacitors from gate–to–drain ( $C_{gd}$ ), and gate–to–source ( $C_{gs}$ ). The PN junction formed during the fabrication of the MOSFET results in a junction capacitance from drain–to–source ( $C_{ds}$ ).

These capacitances are characterized as input ( $C_{iSS}$ ), output ( $C_{oSS}$ ) and reverse transfer ( $C_{rSS}$ ) capacitances on data sheets. The relationships between the inter–terminal capacitances and those given on data sheets are shown below. The  $C_{iSS}$  can be specified in two ways:

- 1. Drain shorted to source and positive voltage at the gate.
- Positive voltage of the drain in respect to source and zero volts at the gate. In the latter case the numbers are lower. However, neither method represents the actual operating conditions in RF applications.



The C<sub>ISS</sub> given in the electrical characteristics table was measured using method 2 above. It should be noted that C<sub>ISS</sub>, C<sub>OSS</sub>, C<sub>TSS</sub> are measured at zero drain current and are provided for general information about the device. They are not RF design parameters and no attempt should be made to use them as such.

#### LINEARITY AND GAIN CHARACTERISTICS

In addition to the typical IMD and power gain, data presented in Figure 3 may give the designer additional information on the capabilities of this device. The graph represents the small signal unity current gain frequency at a given drain current level. This is equivalent to  $f_T$  for bipolar transistors. Since this test is performed at a fast sweep speed, heating of the device does not occur. Thus, in normal use, the higher temperatures may degrade these characteristics to some extent.

#### **DRAIN CHARACTERISTICS**

One figure of merit for a FET is its static resistance in the full–on condition. This on–resistance,  $V_{DS(on)}$ , occurs in the linear region of the output characteristic and is specified under specific test conditions for gate–source voltage and drain current. For MOSFETs,  $V_{DS(on)}$  has a positive temperature coefficient and constitutes an important design consideration at high temperatures, because it contributes to the power dissipation within the device.

#### GATE CHARACTERISTICS

The gate of the MOSFET is a polysilicon material, and is electrically isolated from the source by a layer of oxide. The input resistance is very high — on the order of  $10^9$  ohms — resulting in a leakage current of a few nanoamperes.

Gate control is achieved by applying a positive voltage slightly in excess of the gate-to-source threshold voltage, VGS(th).

**Gate Voltage Rating** — Never exceed the gate voltage rating (or any of the maximum ratings on the front page). Exceeding the rated  $V_{GS}$  can result in permanent damage to the oxide layer in the gate region.

**Gate Termination** — The gates of this device are essentially capacitors. Circuits that leave the gate open-circuited or floating should be avoided. These conditions can result in turn-on of the devices due to voltage build-up on the input capacitor due to leakage currents or pickup.

**Gate Protection** — This device does not have an internal monolithic zener diode from gate-to-source. The addition of an internal zener diode may result in detrimental effects on the reliability of a power MOSFET. If gate protection is required, an external zener diode is recommended.

#### HANDLING CONSIDERATIONS

The gate of the MOSFET, which is electrically isolated from the rest of the die by a very thin layer of SiO<sub>2</sub>, may be damaged if the power MOSFET is handled or installed improperly. Exceeding the 40 V maximum gate-to-source voltage rating, V<sub>GS</sub>(max), can rupture the gate insulation and destroy the FET. RF Power MOSFETs are not nearly as susceptible as CMOS devices to damage due to static discharge because the input capacitances of power MOSFETs are much larger and absorb more energy before being charged to the gate breakdown voltage. However, once breakdown begins, there is enough energy stored in the gate-source capacitance to ensure the complete perforation of the gate oxide. To avoid the possibility of device failure caused by static discharge, precautions similar to those taken with small–signal MOSFET and CMOS devices apply to power MOSFETs.

When shipping, the devices should be transported only in antistatic bags or conductive foam. Upon removal from the packaging, careful handling procedures should be adhered to. Those handling the devices should wear grounding straps and devices not in the antistatic packaging should be kept in metal tote bins. MOSFETs should be handled by the case and not by the leads, and when testing the device, all leads should make good electrical contact before voltage is applied. As a final note, when placing the FET into the system it is designed for, soldering should be done with grounded equipment.

The gate of the power MOSFET could still be in danger after the device is placed in the intended circuit. If the gate may see voltage transients which exceed  $V_{GS(max)}$ , the circuit designer should place a 40 V zener across the gate and source terminals to clamp any potentially destructive spikes. Using a resistor to keep the gate-to-source impedance low also helps damp transients and serves another important function. Voltage transients on the drain can be coupled to the gate through the parasitic gate-drain capacitance. If the gate-to-source impedance and the rate of voltage change on the drain are both high, then the signal coupled to the gate may be large enough to exceed the gate-threshold voltage and turn the device on.

#### **DESIGN CONSIDERATIONS**

The MRF176G is a RF power N-channel enhancement mode field-effect transistor (FETs) designed for VHF and

UHF power amplifier applications. Motorola RF MOSFETs feature a vertical structure with a planar design, thus avoiding the processing difficulties associated with V–groove MOS power FETs.

Motorola Application Note AN211A, FETs in Theory and Practice, is suggested reading for those not familiar with the construction and characteristics of FETs.

The major advantages of RF power FETs include high gain, low noise, simple bias systems, relative immunity from thermal runaway, and the ability to withstand severely mismatched loads without suffering damage. Power output can be varied over a wide range with a low power dc control signal, thus facilitating manual gain control, ALC and modulation.

#### DC BIAS

The MRF176G is an enhancement mode FET and, therefore, does not conduct when drain voltage is applied. Drain current flows when a positive voltage is applied to the gate. RF power FETs require forward bias for optimum performance. The value of quiescent drain current ( $I_{DQ}$ ) is not critical for many applications. The MRF176G was characterized at  $I_{DQ}$  = 100 mA, each side, which is the suggested minimum value of  $I_{DQ}$ . For special applications such as linear amplification,  $I_{DQ}$  may have to be selected to optimize the critical parameters.

The gate is a dc open circuit and draws no current. Therefore, the gate bias circuit may be just a simple resistive divider network. Some applications may require a more elaborate bias sytem.

### GAIN CONTROL

Power output of the MRF176 may be controlled from its rated value down to zero (negative gain) by varying the dc gate voltage. This feature facilitates the design of manual gain control, AGC/ALC and modulation systems.

## PACKAGE DIMENSIONS



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